Fracture Analysis, a Basic Tool to Solve Breakage Issues

Technical Information Paper

Display Technologies

TIP 201 Issued: November 2004 Supercedes: August 2000

and imagination

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Biography

T. Ono received his B. S. and M. S. degrees in inorganic chemistry from Nagaoka University of Technology, Niigata, Japan, in 1988 and 1990, respectively. In 1990, he joined the Shizuoka Technical Center of Corning Japan K. K. where he has been engaged in research and development of the finishing technologies of LCD glass substrate and other glasses. He has also proided extensive fracture analysis support to resolve breakage problems in Customer processes.

Abstract

Breakage of glass substrates in LCD manufacturing processes can cause serious problems of productivity and product quality/reliability. It is known that the mechanism associated with breakage is crack propagation by tensile stress concentration at a damaged point on the glass, which serves as an origin of the breakage [1]. Elimination of breakage requires the elimination of the origin and/or reducing the tensile stress. However, this solution can be applied only if location of origins and the kind of the tensile stresses are known.

Fracture analysis can provide information of both the tensile stress and the origin of breakage [2, 3]. This analytical technique gives important information in determining mechanism of breakage, such as direction of crack propagation, type of the stress, direction of impact and friction, location of the origin. All important information is "memorized" on the broken pieces and can be obtained through microscopic observation. A process where an origin is created is often different from the process where tensile stress is applied. The breakage mechanism can be understood by combining the information from fracture analysis with process information.

The analysis method will be explained using actual cases. Also, the application of the method for optimization of cell-cutting process will be explained.

Glass Breakage

The mechanism of glass breakage is that crack propagates by tensile stress that concentrated at the origin, which is a small damage as cracks on the glass surface, or in the glass body. The relation of the failure stress and size of origin is explained with Eq. 1 [4],

$$\sigma = \frac{1}{Y} \frac{K_{IC}}{\sqrt{c}} \tag{1}$$

where Y is constant depending on the crack and sample shape, K_{IC} is fracture toughness, and c is crack size. Glass having larger crack size, c, could broken at lower failure stress.

Although the stress applied for glass is lower than the failure stress, crack can be propagated in the atmospheric condition, especially by water. This phenomenon is called Subcritical Crack Growth (SCG) caused by stress corrosion, in which the molecular of water cut the Si-O bonding chemically [5]. The durability of the stress corrosion of glass is indicated with n, crack growth parameter. The glass having large n value is durable for SCG, means has long life reliability. The reliability of several kinds of LCD substrate was studied with Gulati et al, and Code 1737 has the highest n value, i.e. has long life reliability entire the LCD substrates [6].

1. Origin

Origins are typically generated by such mechanisms as indentation, impact, or friction during LCD processes. Actually, there are many opportunities to generate these damages during LCD manufacturing. Indentation damage is irregularly generated when substrates are clamped or chucked on process stages where foreign particles, especially glass particles, are present. Therefore, once the breakage occurs, appropriate cleaning of the glass chips, etc. in the process is essential to prevent secondary breakage. Size of the damage as crack by indentation has been studied using Vickers point indentation [7]. The general relation between crack size and load is explained with Eq. 2,

$$c^{\frac{3}{2}} = \chi \frac{P}{K_{IC}}$$
(2)

where c is crack size, *P* is load, K_{IC} is fracture toughness. χ is a constant which relates to the material properties and geometry of indenter.

Damage by impact, which is principally the same as indentation but loading speed is much faster than that of indentation, is generated mainly on the substrate edge by rapid contact with the supporting rods of the cassette or the alignment pins. This damage is easily generated because stress is localized by point contact. Friction damage is created when placing glass into cassettes, rubbing with the alignment pins, and sliding on the lithography stage. This damage mode usually occurred after impact when the loading direction of the impact is not perpendicular to the surface or edge. When the friction damage is created, it can often be invisible, but becomes visible after acid etching.

Stress

Tensile stress is the force needed to propagate damage during substrate breakage. Actually, thermal and mechanical stresses are main sources of tensile stress in the LCD process. Thermal stress for the crack propagation is generated when a heated glass substrate is cooled, which can create tensile stress along the substrate edge. The magnitude of the stress is a function of temperature difference, ΔT , as shown in Eq. 3 [8],

$$\sigma = \lambda \frac{E\alpha \Delta T}{(1-\nu)} \tag{3}$$

where α is Coefficient of Thermal Expansion (CTE), E is Young's modulus, Δ T is temperature difference between inside and surface of the glass, v is Poisson's ratio. λ is a constant that depends on Bio's constant that relates to the thermal conductivity of the glass and thermal diffusibility of coolant. The constant is 0.7 when the coolant is air.

In addition, CTE mismatch between glass and deposited film material increases the magnitude of stress. Mechanical stress is usually due to bending during handling of the substrate, which is generated when flat glass substrate is warped, frequently due to deposited film – substrate CTE mismatch. Bending stress is also generated when warped substrates become flat by vacuum chucking, or clamping. Panel sag during handling also generates bending stresses. Tensile stress by bending is generated not only at the edges, but also at glass surfaces. The tensile stress σ created by bending can be also calculated with Eq. 4 [9],

$$\sigma = \beta \, \frac{wa^2}{t^2} \tag{4}$$

where *w* is uniform load, *a* and *t* are short edge length and thickness of the glass substrate, respectively. β is the constant which decided ratio of short/long edges length.

Another source of mechanical stress is centrifugal stress by rotation at spin-drying or spin-coating processes. Stress increases with substrate size and with rotational speed.

In general, the failure stress has been used to evaluate mechanical strength of glass. However, the failure stress is strongly influenced by the size of the origin (nonconformity) on the glass substrate as indicated with Eq. 1. Understanding origin size and mechanism of breakage is useful information for identifying and eliminating breakage during LCD process. In the actual case, glass can be broken under the failure stress as calculated with Eq. 1 due to the residual stress created by damage such as impact or friction. These residual stresses accelerates the crack opening.

Fracture Analysis

When glass is broken, "footprints" of cracks are "memorized" on the fracture surfaces. These "footprints" map the fracture event and are strongly related to the origin creation, crack propagation and applied stress. Fracture analysis is structured with two parts, (1) observe the "footprints" on fracture surface to bring the information of origin and tensile stress, and (2) analyze the information with process information to identify the breakage mechanism. Table 1 shows the steps of the fracture analysis until obtaining the solution of the breakage issue [10].

Table 1.	Process	steps	of fracture	analysis
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A. Obtain information	B. Obtain information from fracture surface
from glass surface	Wallner lines,
Forking,	Hackle marks,
Hertzian cone,	Mirror region,
Chatter mark,	Sharra scarp,
Residue	Origin
C. Proces	s information
Contact point/m Contact speed/c Thermal cycle, Breakage loss/t	lirection, especially cooling condition,
D. Perma	ment Solution

Fracture analysis has been applied to various glass breakages events encountered in LCD manufacturing processes, and has provided enough information to identify where the breakage originated and how the flaw propagated. Source of the information is on two surfaces, glass and fracture surfaces as shown A and B in Table 1.

The details of information taken with the fracture analysis is well summarized in references [1-3, 10,12,13]. Brief explanation of these information are performed below.

A. Information from Glass Surface

<u>Forking</u>: Forking is crack branching. Qualitative magnitude of applied stress can be known from number of cracks forking as shown in Fig. 1.

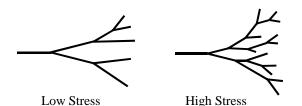


Fig. 1 Forking with high and low stresses

<u>Hertzian cone</u>: Hertzian cone crack is created by localized impact with blunt hard object. Schematic illustration of the Hertzian cone creation is shown in Fig. 2.

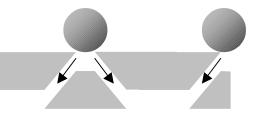


Fig. 2 Schematic illustration of Hertzian cone crack creation from cross sectional view.

<u>Chatter mark</u>: Chatter marks is created by friction, and its shape indicates direction of the friction. Cracks curves concavity toward rubbing direction as shown in Fig. 3.

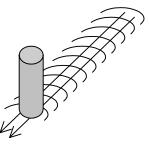


Fig. 3 Schematic illustration of relation between friction direction and shapes of Chatter marks. Drawing shows that the glass is stationary and the object is moving in the direction indicated by the arrows.

<u>Residue</u>: Residue brings many information not only kind of material of contacted, but also timing when origin is created or when crack was run. Patterns on the glass surface such as TFT is one of residue from view point of fracture analysis.

B. Information from Fracture Surface

Wallner lines: Wallner lines are rib shaped marks as shown in Fig. 4, which indicate crack propagation direction. The Wallner line is perpendicular to the crack propagation direction. There are three types of Wallner lines that are very useful in determining the coarse of events. These are primary, secondary and tertiary. Primary wallner lines indicate that a surface or internal flaw was present prior to the failure event. Secondary wallner lines occur when the fracture approaches terminal velocity, and tertiary occur as a result of a mechanical shock, vibration or impact outside the crack front.

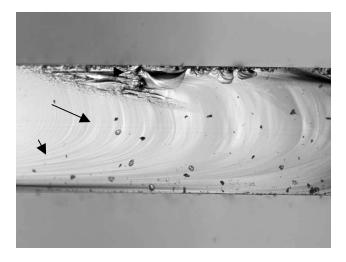


Fig. 4 Secondary Wallner lines created by crack propagation with bending stress. Cracks run left to right (arrow mark).

<u>Hackle marks</u>: Hackle marks are a definitive indication as to crack propagation direction. Typically two kinds of hackle marks can been seen, which are (1) twist hackle, appeared at region where the tensile stress tilted (twisted) from crack surface (Fig. 5), and (2) mist hackle appeared around origin (Fig. 6). Mist hackles are commonly referred to as velocity hackle.

<u>Mirror region</u>: Around an origin, especially when tensile stress was high, mirror region can be seen. The applied tensile stress can be calculated from radius of the mirror region [11].

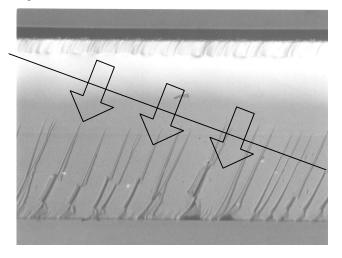


Fig. 5 Typical Twist Hackle mark created by breaking process following scribe process. Crack front was perpendicular to the Twist hackle marks, and crack propagation direction was parallel to the mark.

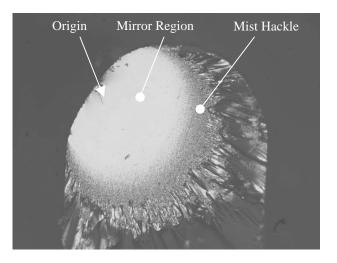


Fig. 6 Fracture surface around origin. Origin is surrounded with mirror region, which is covered with mist Hackle mark. Failure stress can be estimated using radius of the mirror region.

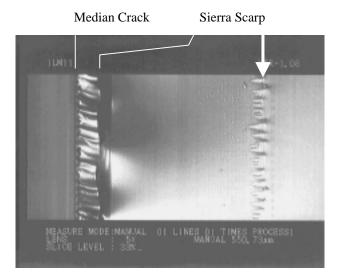


Fig. 7 Sierra Scarp appears on a fracture surface created by scribe/break process. Water was existed during median crack propagation

<u>Sierra scarp</u>: When water is exist at crack front during the crack propagation, Sierra scarp appeared.

Actual Step of Fracture Analysis

Procedure of the fracture analysis when a breakage is reported is explained using typical case [12]. This case is that breakage on three substrates were found when the sheets were unloaded from film deposition chamber. A crack was running a sheet to separate into two pieces. The crack shape of three sheets are shown in Fig. 8.

(1) Collect all broken pieces

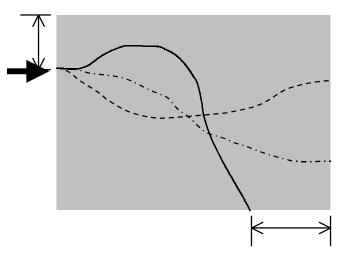


Fig. 8 Crack map of three broken sheets.

Every important information is on the broken pieces. It is very important for the fracture analysis that the fracture surface should be kept from any additional mechanical damages to remain information. Additional damage such as chipping by friction can erase the information easily. In this case, a sheet was separated already, so two pieces were separately kept.

(1) Make crack maps

Mapping the crack running feature is important to make the analysis easily. It is important to note that you don't play zig-saw puzzling of broken pieces, because the puzzling makes secondary damages. Rough sketch of the crack forking is enough. Also, distance between crack end crossing an edge and the nearest corner is important information for the identifying contact point on edges in processes.

In the case, crack map of three broken pieces were obtained as shown in Fig. 8. One of two crack ends on each broken sheet are located at same position (arrow mark). This information indicates that probability of existing origin at this point is high. If a machine creates damage, its location is precisely same due to its high repeatability to compare with manual.

(3) Identify crack propagation direction

The crack propagation direction is identified with observation of the Wallner lines or Hackle marks to look for a location of origin of the breakage. Not only the crack propagation direction, but also type of the applied stress can be identified from the results of this observation. In the case, wallner lines which is almost perpendicular to the surface are seen in the middle of fracture surface as shown in Fig. 9. These Wallner lines indicate two things, (1) that the thermal stress possibly contributed to propagation of this crack and (2) crack runs right to left.



Fig. 9 Wallner lines on fracture surface Thermal stress is one stress that can generate this shape of Wallner lines. Crack run right to left.

(4) Identify origin

Following opposite direction of crack propagation, origin should be there. The way to identify the origin is three:

- 1. Find defect at the center of mirror region, which surrounded with mist hackle mark.
- 2. Find defect at the center of hackle marks running radial.
- 3. Find defect at center of semicircle Wallner lines

Figure 10 shows around origin. Origin can be identified at the apex of round edge (arrow mark) by (1) center of radial Hackle marks and (2) center of semi circular Wallner lines. This point was same as the point that mapping result indicated a potential location of origin.

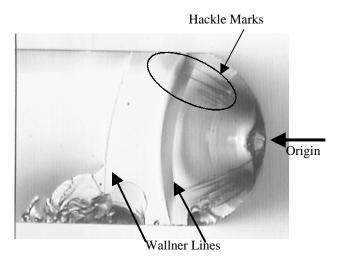


Fig. 10 Fracture surface around origin. Radial Hackle marks, symmetrical Wallner lines with Arrest lines are existed

(5) Identify root cause of origin creation

After the identifying the origin, observation around the origin is performed to obtain the information related to origin creation. If the residue was existed, material identification should be done using SEM/EDX or FTIR. Small cracks by mechanical damage become visible after appropriate etching.

On the case, ground edge around the origin was observed, and result is shown in Fig. 11. Obtained information was:

- 1. There is residue, which shines brightly at the apex near the origin.
- 2. Due to the residue position, only at apex, it is assumed that shape of rubbed something could be bar or pin, and its direction is perpendicular to the edge direction.
- 3. Shape of origin is curved, and hidden cracks having same shape as that of origin was confirmed (it is difficult to see in this picture). This information says that the origin was one of Chatter marks, created by friction. And rubbing direction was identified parallel to the edge by the shape of the chatter mark.

Generally, metallic material can be seen shiny by optical microscope with reflective light source. The residue was analyzed with SEM/EDX to identify its material. The result indicated that the metallic material was Stainless steel. Preliminary summary of mechanism of origin creation is that a something made of stainless steel rubbed apex of ground edge, created Chatter mark and left metal residue. The chatter mark became origin of breakage when thermal stress was applied.

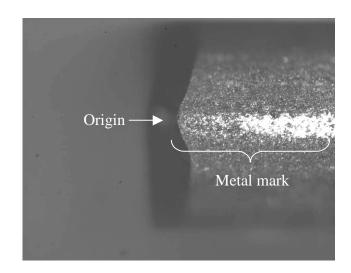


Fig. 11 Around the origin. This picture was taken from apex of the ground edge. Vertical axis in this picture is thickness direction.

(6) Combine with process information

From the preliminary summary of the mechanism of the breakage, necessary information for the analysis are squeezed such as

- 1. Contact point where hit a position, which pointed out by mapping.
- 2. Contact was done by <u>machanically</u>, not manual due to high repeatability.
- 3. Contacted material should be Stainless steel, and
- 4. Shape of the metal is pin or bar
- 5. The contact should happen before CVD cooling process.

From these conditions, the customer found process where stainless steel pin is used for alignment of sheet. And the surface of the pin was abraded by ground edge.

(7) Identify the mechanism of the breakage

Finally, information obtained from broken piece and processes are considered to identify the breakage mechanism. In summary of this case, damage was generated by the glass edge rubbing with the alignment pin when the substrate was pushed toward the pin as shown in Fig. 12. After the film deposition, the crack propagated from the origin by tensile stress, which was created parallel to the edge when the substrate is cooled down from 200-300°C to room temperature.



Fig. 12 Schematic illustration of the identified mechanism of origin creation on the case. Actually, glass sheet slides with direction of arrow mark with fixed pin, and relative rubbing direction by pin is opposite (left to right in this figure).

Application of the Fracture Analysis for the Cutting Process Optimization

The fracture analysis also can be applied to the optimization of cell/glass cutting process. Scribe/break method is widely used as glass cutting method. The glass sheet first scribed to create median crack with WC wheel as designed. Tensile stress is then applied with hitting on back side surface of scribed surface, or, bending to separate the glass sheet by propagation of the median cracks.

Therefore, glass cutting process using scribe/break method is a controlled breakage, where the crack propagates only along the scribe line. Cracks of the glass sheet cutting is the controlled breakage shown in Fig. 13. The scribe line, is an origin of the breakage, which crack propagation along with the scribe line is origin of separation of the sheet. The fracture analysis is useful tool for the optimization of the process, and/or analyze cause of faulty cutting, cracks run freely.

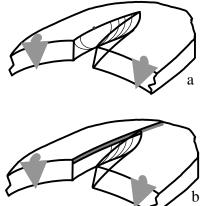


Fig. 13 Schematic illustration of (a) breakage and (b) cutting. Only difference between (a) and (b) is origin of crack propagation. Irregularly created damage as origin for breakage (a) and median cracks created with scribing as controlled origin for the cutting (b).

The typical fracture surface by good cutting (called "Cut surface") is shown in Fig. 14. Median crack, approximately 100μ m in depth is uniformly created, and the median crack propagated portion was smooth, due to low and stable breaking force.

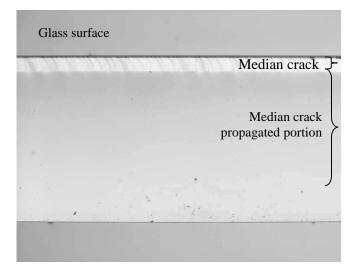


Fig. 14 Typical fracture surface by good cutting. Median crack depth is stable, and the median crack propagated portion is smooth.

In contrast to that, Figs. 15 and 16 show some faulty cut surfaces [13]. When individual LCD cells are separated in the final stages of LCD manufacture, the fracture plane sometimes deviates from the score-line. Even when scoring is done properly, i.e., the median crack is deep enough, this break failure is (also called mis-break) can result from inappropriately applied stress during separation. In Fig. 16, although the median crack is deep enough, the fracture surface deviates from the median crack. This fact shows that the tensile stress on the opposite surface of the scribed side is higher than that on scribed side. The mechanical stress of impact during cell separation process could also provide sufficient additional stress to cause mis-break.

Fig 16 shows insufficient median cracks often created when the scribe wheel becomes worn or the scribe force too low to maintain the median crack. Left side median cracks created uniformly, but on the right side, radial cracks were created. The radial crack is created just front of scribe wheel contact portion. It is shallower than median crack depth at same scribe load, and wavy surface. This crack easily diviated from the scribe line. Scribe wheel run from left to right.

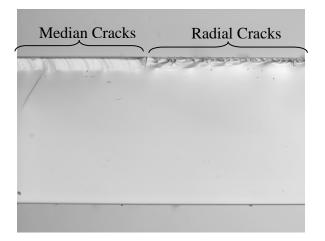


Fig. 16 Cut surface where the median crack stopped. Scribe wheel runs left to right.

Key information for the optimization of the cutting process are Wallner lines and Hackle marks at the median crack propagated portion, as well as median crack feature.

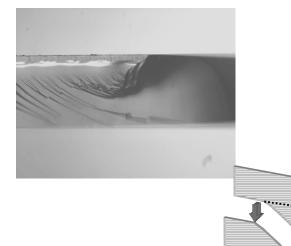


Fig. 15 Fracture surface of miss-breaking sheet by inappropriate separation [13].

Conclusion

1. Fundamentals and applications of fracture analysis, the effective tool to solve the breakage problem, is explained. The fracturte analysis can bring reliable evidence of breakage from broken pieces. Once the mechanism of the breakage can be identified with the collected evidence, appropriate solution can be secured.

2. Also, effectiveness of the fracture analysis for the cutting process optimization is explained. Fracture analysis is applicable for the optimization, because thecutting process using scribe/break method is a controlled breakage.

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Acknowledgments

Authors would like to thank to J. E. Bayne, P. L. Bocko, Y. Imamura, and G. A. Luers for technical discussions.

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